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Dated: February 10, 2005 Signature:

(Michael R. Hull)

Docket No.: 30205/39512
(PATENT)

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Patent Application of:
Sung Koo Lee et al.

Allowed: February 3, 2005

Application No.: 10/719,355

Confirmation No.: 3322

Filed: November 21, 2003

Art Unit: 1752

For: PHOTORESIST POLYMER AND
PHOTORESIST COMPOSITION
INCLUDING THE SAME

Examiner: Sin J. Lee

COMMENTS ON STATEMENT OF REASONS FOR ALLOWANCE UNDER 37 CFR §1.104(E)

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Dear Sir:

In addition to the reasons for allowance set forth in the allowance papers that were mailed in connection with the present application, it is respectfully submitted that the claims are allowable for the additional reasons that the invention defined by the language of the claims is neither anticipated by, nor would have been obvious when taken as a whole in view of, the art of record.

Dated: February 10, 2005

Respectfully submitted,

By
Michael R. Hull

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